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## APPARATUS AND METHOD FOR COATING OBJECTS THROUGH PVD

- The present invention relates to an apparatus for coating objects by means of PVD (Physical Vapour Deposition), comprising:
  - a preprocessing device for performing a preprocessing on the object;
- a PVD device for coating the object under an atmosphere differing from the ambient; and
- a postprocessing device for postprocessing the objects.
- 15 for instance used to apply a thin layer of metal on plastics to give the object the appearance of metal. Examples hereof are for instance caps for cosmetics bottles, prizes such as presented at sporting events, car components and the like.
- According to the prior art the objects for processing are placed on racks and provided with a lacquer coating. This lacquer coating enhances adhesion between the plastic from which the object is made and the metal coating to be applied thereto. The lacquer coating moreover provides a smooth surface, so that the reflection of the metal to be coated thereon is improved.

It is further pointed out that the pretreatment can also comprise a treatment prior to lacquering, such as a flame treatment. The surface properties of the 30 plastic object are hereby changed so that the lacquer adheres better to the plastic.

The objects for processing are subsequently placed in a vacuum vessel.

A vacuum is then created in the vacuum vessel 35 and, by means of evaporation of metal objects, metal vapour is introduced in the vacuum vessel which deposits on the lacquered components. This process is known as "Physical Vapour Deposition" (PVD).

After complete evaporation of the relevant element, air is again admitted into the vessel, whereafter the thus metallized objects on the racks can be removed.

The objects are thereafter subjected to a posttreatment, which is generally formed by a new lacquer
treatment. It is pointed out here that the applied metal
layer is extremely thin and is easily damaged. In order
to protect this layer a protective lacquer coating is
therefore applied. This lacquer coating further provides
the option of changing the colour. In general use is made
of aluminium as PVD material, wherein it is possible by
colouring the lacquer to change the colour to for
instance gold or copper colour.

A problem with this method generally used heretofore is that many operations must inevitably be performed manually, requiring much human labour. This is caused by the discontinuous character of the PVD process and by the relatively long drying time of the lacquers once they have been applied to the plastic objects. The work is moreover usually difficult.

therefore to provide an apparatus with which metal coating with the associated preceding and following operations can take place as far as possible in autom

25 operations can take place as far as possible in automated manner:

This object is achieved in that the apparatus comprises a transport device which extends through the preprocessing device, the PVD device and the

30 postprocessing device; that the transport device is adapted to transport objects arranged on carriers and that the PVD device is adapted for semi-continuous treatment of objects arranged on the carriers.

The semi-continuous character of the PVD device 35 enables successive treatment of the carriers with a series of objects. Because the transport device is adapted for this purpose, and moreover extends through the preprocessing device and postprocessing device, it

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becomes possible to treat the objects for vapour deposition without loading and unloading operations. This combination of measures thus enables the use of a certain degree of automation; only at the start do the objects have to be placed on the carriers, and after completion of the postprocessing they can be removed therefrom. Handling of the objects between the treatments, albeit placed on racks, is dispensed with.

According to a preferred embodiment the

10 carriers are elongate and the transport device is adapted
to move the carriers substantially in the longitudinal
direction.

This configuration has the advantage that the objects arranged on the carriers are always readily accessible for the devices for applying lacquer and the like.

According to another preferred embodiment the PVD device is connected to the ambient by means of a single lock, the transport device extends through the lock and the lock is adapted to feed a carrier simultaneously into and out of the PVD device.

This provides the option of applying a single lock construction, these being generally expensive.

According to yet another preferred embodiment 25 the transport device has a closed configuration and extends in two directions through the PVD device.

This also results in an attractive construction; when for instance further lock constructions are used, they can likewise be used in both directions, while the construction length of the apparatus can moreover be shortened by using it on two sides.

In addition, it is attractive to use buffers between the preprocessing device and the PVD device, and 35 between the PVD device and the postprocessing device. These buffers have the function of compensating for the semi-continuity of the process performed in the PVD devices.

in transverse direction, the buffers take up less space.

According to a particular preferred embodiment, the preprocessing device comprises a blower device for 5 blowing dust from the objects for treating.

This blower device is preferably adapted to blow ionized air.

According to another preferred embodiment the preprocessing device comprises an application device for applying onto the objects for treating a lacquer which cures with UV radiation, as well as a UV radiation device.

The use of lacquer which cures with radiation enables shortening of the drying time, this being one of the most significant drawbacks of the prior art. The use of lacquer which cures with radiation considerably shortens the drying time, so that the objects thus provided with a lacquer coating can be subjected more rapidly to the following processing.

According to yet another attractive preferred embodiment, the preprocessing device comprises a surface processing device connected prior to the application device for processing the surface of the objects for treating.

This is understood to mean for instance a corona device. The properties of the surface of the objects for treating are herewith changed so as to improve adhesion with the lacquer.

The advantage of the lacquer which cures with 30 radiation applies not only in the pretreatment but also in the post-treatment.

An attractive preferred embodiment further results when a loading/unloading station is placed between the postprocessing device and the preprocessing device for unloading processed objects and loading objects for processing.

This configuration has the advantage that loading and unloading, i.e. the major part of operations

to be performed by human intervention, take place within the same area. This not only has logistic advantages, but also advantages in the field of hygiene and working conditions.

5 Loading and unloading are understood to mean operations wherein the carriers remain on the transport path and the processed objects are exchanged for objects for processing, as well as operations wherein the carriers are removed from the transport path in their 10 entirety and are re-placed on the transport path and wherein the actual loading and unloading of the carriers takes place at another location.

According to yet another preferred embodiment the carriers are provided with interchangeable object 15 holders.,

This measure provides the advantage that the carriers can be used for different types of object; only the object holders have to be exchanged. This is particularly important in respect of the cost of the carriers; these carriers after all comprise expensive components manufactured with great precision.

In order to expose the objects properly on all sides to the processes to be applied, it is advantageous when the object holders are placed on vertically extending shafts mounted rotatably in the carriers.

This advantage is further enhanced when toothed wheels are arranged on the shafts for driving the shafts in rotation.

Because application of the lacquer in
30 particular usually involves waste, it is important for
the toothed wheels to be protected against this. For this
purpose they are preferably arranged under the top side
of the carrier. This provides the option of arranging
protective means, so that lacquer dripping from the
35 objects cannot reach the toothed wheels.

According to another preferred embodiment the toothed wheels are let into openings arranged in the carrier and the toothed wheels protrude outside the side

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walls of the carrier. This provides the possibility of providing the transport device with gear racks or chains for engaging in and rotating the toothed wheels during passage of the carriers, so that the shafts, and the 5 objects placed thereon by means of the object holders, can thereby be rotated.

The present invention will be elucidated hereinbelow with reference to the annexed drawings, in which:

figure 1 shows a perspective schematic view of a complete apparatus according to the present invention; figure 2 shows a perspective schematic view of the loading and unloading station of the apparatus shown in figure 1 as according to arrow II in figure 1;

figure 3 is a detail view as according to arrow III in figures 1 and 2;

figure 4 shows a perspective view of the buffer device according to the present invention as according to arrow IV in figure 1;

figure 5 is a perspective detail view as according to arrow V in figure 4;

figure 6 is a perspective detail view of
figure 5;

figure 7 shows a perspective detail view as 25 according to arrow VII in figure 4;

figure 8 shows a perspective detail view as according to arrow VIII in figure 4;

figure 9 shows a partly broken away perspective view of a vacuum evaporation chamber; and

figure 10 shows a perspective view of a carrier which is provided with diverse insert elements for arrying diverse objects for processing.

Figure 1 shows a metallizing apparatus designated in its entirety as 1. Broadly speaking, this metallizing apparatus is formed by a magnetron sputtering device 2, a preprocessing device 3 and a postprocessing device 4. Extending through each of these devices is a transport device 5. A shunting area 6 is arranged between

preprocessing device 3 and PVD device 2 and between PVD device 2 and postprocessing device 4.

This shunting area serves to compensate for timing differences between the continuously operating 5 preprocessing device 3 and postprocessing device 4 and the semi-continuously operating PVD device 2. Transport device 5 is closed and extends in both directions through PVD device 2. Between postprocessing device 4 and preprocessing device 3 the transport device 5 extends 10 through a loading and unloading zone 7.

This loading and unloading zone is further shown in figure 2. This shows that transport device 5 has a U-shape at this location. At the positions where transport device 5 forms an angle are arranged rotation devices 20, each comprising a rotating disc 21. By means of rotating discs 21 it is possible to rotate carrier 15 through an angle of 90°. In order to move carriers 15 onto rotating discs 21 use is made of the drive device which is integrated into transport device 5. In order to move the carriers off the turned rotating disc 21 onto the following part of transport device 5, use is made of a pushing element 22 drivable by a linear drive element 23 arranged above the rotating disc.

The objects 24 for processing are placed on 25 carriers 15 on that part of the transport device 5 placed between the two rotation devices 20. This part forms the loading zone 7A.

The finished products 24 can be taken off the part of transport device 5 preceding rotation device 20.

30 This is the unloading zone 7B.

Figure 2 further shows how a check gate 25 is placed after the second rotation device 20 for checking the presence of and the location in a plane perpendicular to the direction of movement of the objects for treating.

35 The presence detection is important for controlling for instance the lacquer device, so as to prevent an excessive quantity of lacquer being wasted by spraying while no object is passing.

The location detection serves to prevent objects placed askew on the holders from disrupting the movement of the carriers, whereby objects could become jammed or fall off. This would result in stopping of the process, removal of the objects in question and restarting of the process.

The first gate 25 placed after the loading station therefore serves mainly to determine whether the objects are placed correctly. Such a gate is also placed before the vacuum device. In the vacuum device the position of the objects is after all critical, and space is limited, this being particularly important in the case of large objects. Furthermore, the location of the objects on the carrier may have been changed due to the action of the spraying device.

Figure 3 further shows the construction of transport device 5 at the location of unloading zone 7B.

Shown in figure 3 is that part of the transport device which functions as unloading station.

The transport device comprises two tubular profiles 26 which are provided at regular distances on their underside with bearing units 27, in which are mounted shafts 28. A support wheel 29 is arranged on each of the shafts 28. Further arranged are two U-shaped profiles 30 which are each fixed against tubular profiles 27. In one of the two U-shaped profiles 30 is arranged a drive chain 31, which is provided with catch elements 32 for moving the carriers 15 along. The chain is guided back again via the underside of the transport device.

30 This transport device extends through the entire apparatus according to the invention.

Carriers 15 are each formed by a carrier body 36, in which are mounted vertically extending shafts 16. Carrier body 36 is provided with recesses 18 through which shafts 16 extend and wherein toothed wheels 17 are arranged on the shafts at the location of recesses 18. These toothed wheels 17 serve to drive the shafts in

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rotation when for instance a gear rack or movable chain is arranged along the sides of profile 26.

Each of the shafts are provided on their top with a recess 33 on which extension shafts 34 can be 5 placed. Product holders adapted to the product for processing, which will be described with reference to figure 10, can then be placed on top of extension shafts 34. It is pointed out here that it is possible to use extension shafts 34 of different heights, so that it is possible to adjust the height of the objects for processing on the carriers.

A part of the profile 30 can otherwise be folded down at the location of unloading station 7B, so that carriers 15 can be taken away.

15 Further shown in figure 4 is a buffer device 6 which provides the synchronization of the essentially continuously operating preprocessing and postprocessing device and the semi-continuously operating vacuum metallization device.

Buffer device 6 is formed essentially by a frame 35 on which are placed two shafts 37, one of which is drivable by means of a motor 38. A chain wheel 39 is placed on each of the shafts 37, wherein a chain 40 is trained around each pair of chain wheels 39. Supports 41 are arranged between the two chains 40 for transporting carriers 15.

Shaft 36 is herein set into intermittent rotation such that supports 41 move intermittently. During the standstill periods of these carriers, the carriers from UV radiation device 10 are loaded onto the support 41 placed in line with transport device 5, while the carrier then placed in front of the transport device of the vacuum metallization device is simultaneously pushed onto the transport device of the metallization device by means of a pushing device 42. A carrier coming from the metallization device is simultaneously pushed onto the relevant support 41 and a carrier placed in front of the transport device of the UV lacquer spraying

device 12 is pushed onto the relevant transport device. The device in question then moves one full stroke, whereafter this process is repeated.

Figure 5 shows how a pushing device 42 is 5 arranged for pushing a carrier 15 onto the relevant support 41. This pushing device 42 is herein driven by a linear drive member 43.

This device further shows how the shafts 16 of carrier 15 can be driven in rotation by means of toothed 10 wheels 17, this independently of the linear movement of carrier 15. Use is made for this purpose of a chain 46, a part of which is arranged parallel to the direction of movement of carrier 15 and which can be driven independently of the transport movement. It will be 15 apparent that it is possible to make use instead of for instance gear racks. These are then arranged fixedly so that the rotation movement is in fact coupled to the transport movement.

Various aspects are shown in more detail in 20 figure 6.

Figure 7 shows in more detail the mechanism with which the movements of supports 41 to the transport device 5 within the vacuum metallization device are executed, and vice versa.

This shows the construction of the linear drive device 43 which is connected by means of a frame 47 to a pushing device 44.

drive device for transport of carriers 15 inside the

30 vacuum metallization device. The relevant elements are
herein mounted on a plate 50, on which are arranged two
beams 51 on which guide wheels with guide shafts 52 are
mounted. In the middle of each of these beams 51 a guide
wheel 52 is further arranged on the other side of the

35 path of the carrier. Finally, support wheels 53 are
arrangeds

Drive wheels 55 are also arranged for driving the carrier 15. Drive wheels 54 are herein driven by

WO 00/28105

means of belts 55. Both belts 55 are trained round a wheel 56 which is driven by a motor mounted beneath the plate. This drawing also shows that a check gate device is again placed in order to determine whether all objects 5 are present on the carrier.

Figure 9 shows the construction of the vacuum metallization chamber 4, which otherwise forms the subject-matter of the European patent application 98.203444.9. Here also the same drive device is used.

10 This is further of importance in that plates 57 are arranged to protect the transport device against precipitation of metal. Such plates are otherwise also arranged in the paint spraying devices.

This figure further shows how the actual
15 targets 58 of the magnetron sputtering device are
arranged at two different levels. In combination with the
different heights of the extension shafts it is thus
possible to determine the height and direction of the
metallization process.

In the present construction the objects for processing pass twice through the magnetron sputtering device, wherein only one of the two passages is effective. The active half of the device is separated from the non-active half of the device by a partition wall 59 of a material on which the sputtered vapour will deposit but which can be removed easily.

product carriers 15. The product carriers are placed on top of the extension shafts to carry the products for processing. In the present case the product carriers are formed by a piece of threaded end which can be placed on the extension shaft, wherein discs provided with internal thread can be placed on the threaded ends, the form and position of which discs can be adapted to the relevant

35 products.